



Time Resolution Studies of Low Gain Avalanche Detectors Fabricated at Micron Semiconductor Ltd.

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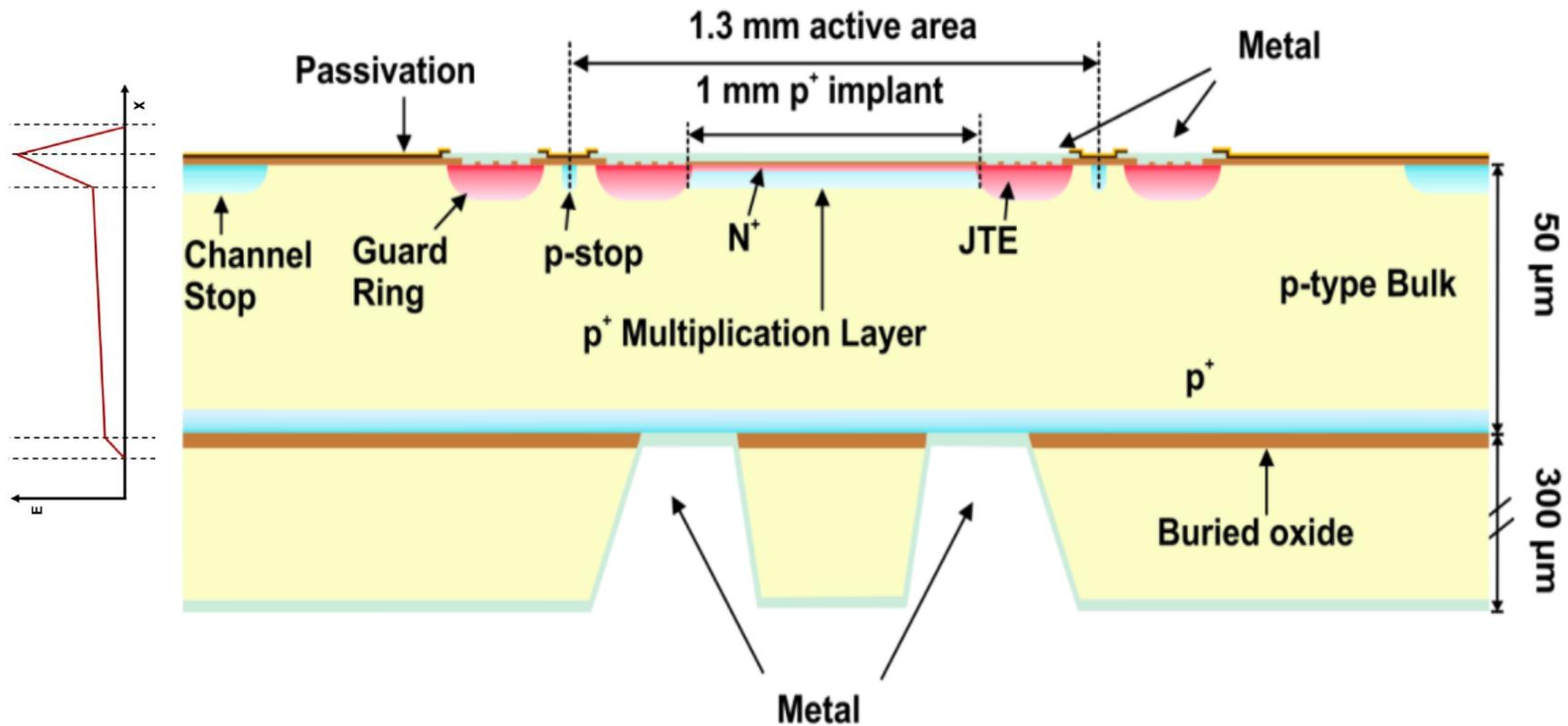
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Low Gain Avalanche Detectors Design (Briefly)

- LGADs have a p^+ multiplication layer near cathode
- Allows high E-field in region

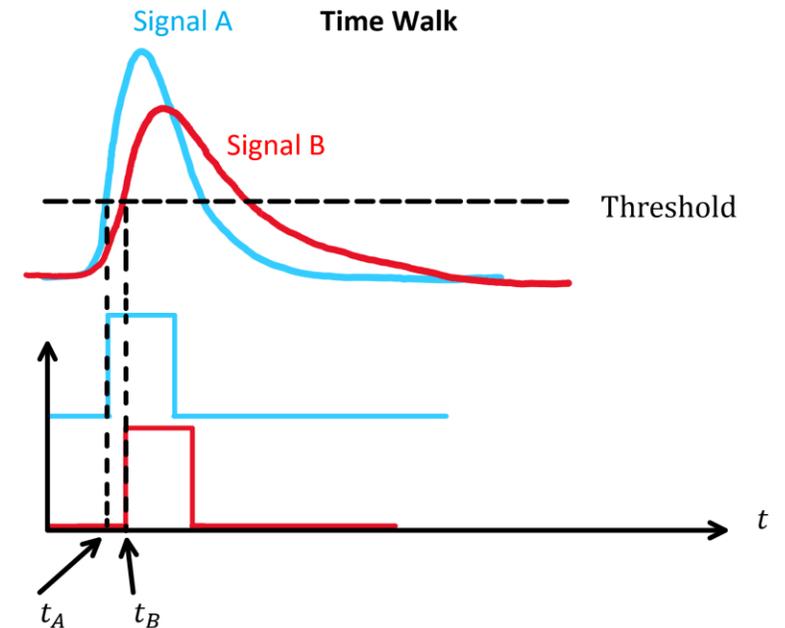
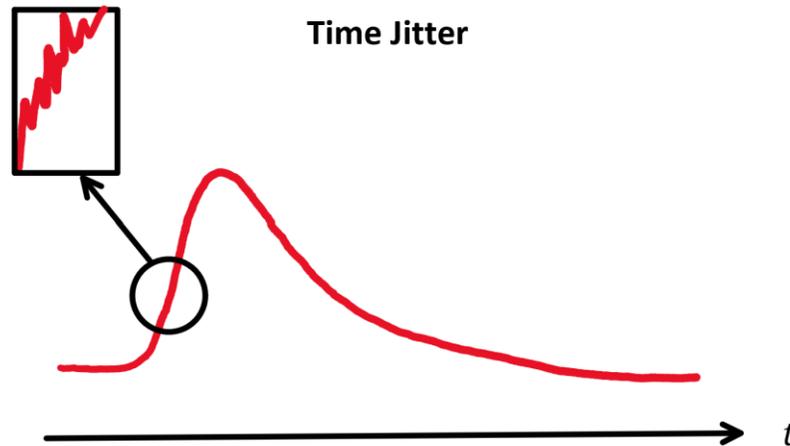


Timing Resolution Dependence

- Time resolution of LGADs dependent on different parameters:

$$\sigma_{Total}^2 = \sigma_{Jitter}^2 + \sigma_{Time\ Walk}^2 + \sigma_{TDC}^2 + \sigma_{Landau\ Noise}^2 + \sigma_{Distortion}^2$$

- Jitter
- Time Walk
- Time to Digital Converter (TDC)
- Landau Noise
- Distortion



Requirements for Timing Detectors

- LGADs must be optimised to get excellent time resolution

$$\sigma_{Total}^2 = \sigma_{Jitter}^2 + \sigma_{Time\ Walk}^2 + \sigma_{TDC}^2 + \sigma_{Landau\ Noise}^2 + \sigma_{Distortion}^2$$

$\sigma_{Jitter} \approx \frac{t_{rise}}{\left(\frac{S}{N}\right)} \Rightarrow \text{maximise } \frac{S}{t_{rise}} \Rightarrow \text{go thin}$

$\sigma_{Time\ Walk} = \left[\frac{V_{th}}{S/t_{rise}} \right]_{RMS} \Rightarrow \text{maximise } \frac{S}{t_{rise}} \Rightarrow \text{go thin}$

Negligible; not from sensor

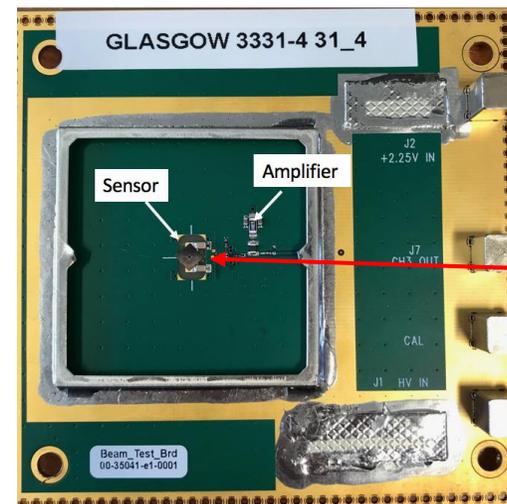
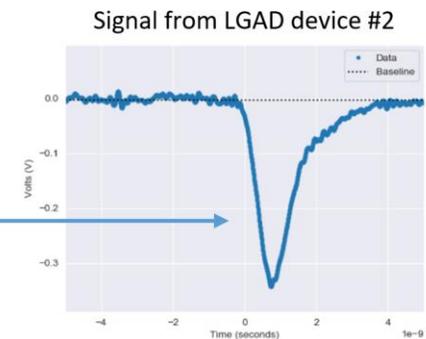
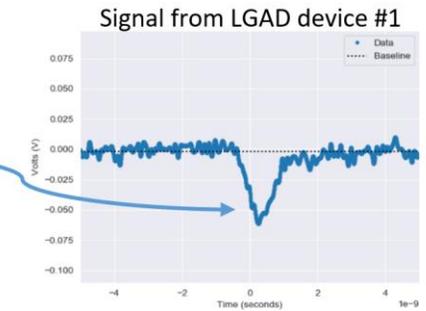
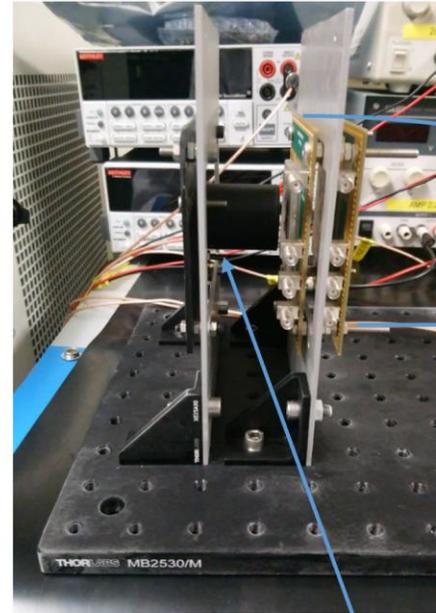
Simulations indicate thin detectors reduce Landau Noise

Uniform weighting field and operate at saturated drift velocities

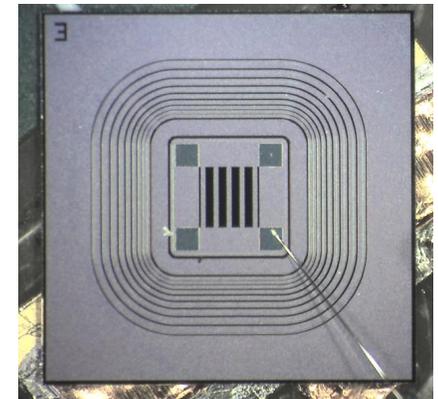
- Best timing resolution obtained by $\sim 50\mu m$ sensor thickness and higher gain of ~ 20

Experiment for Timing Studies

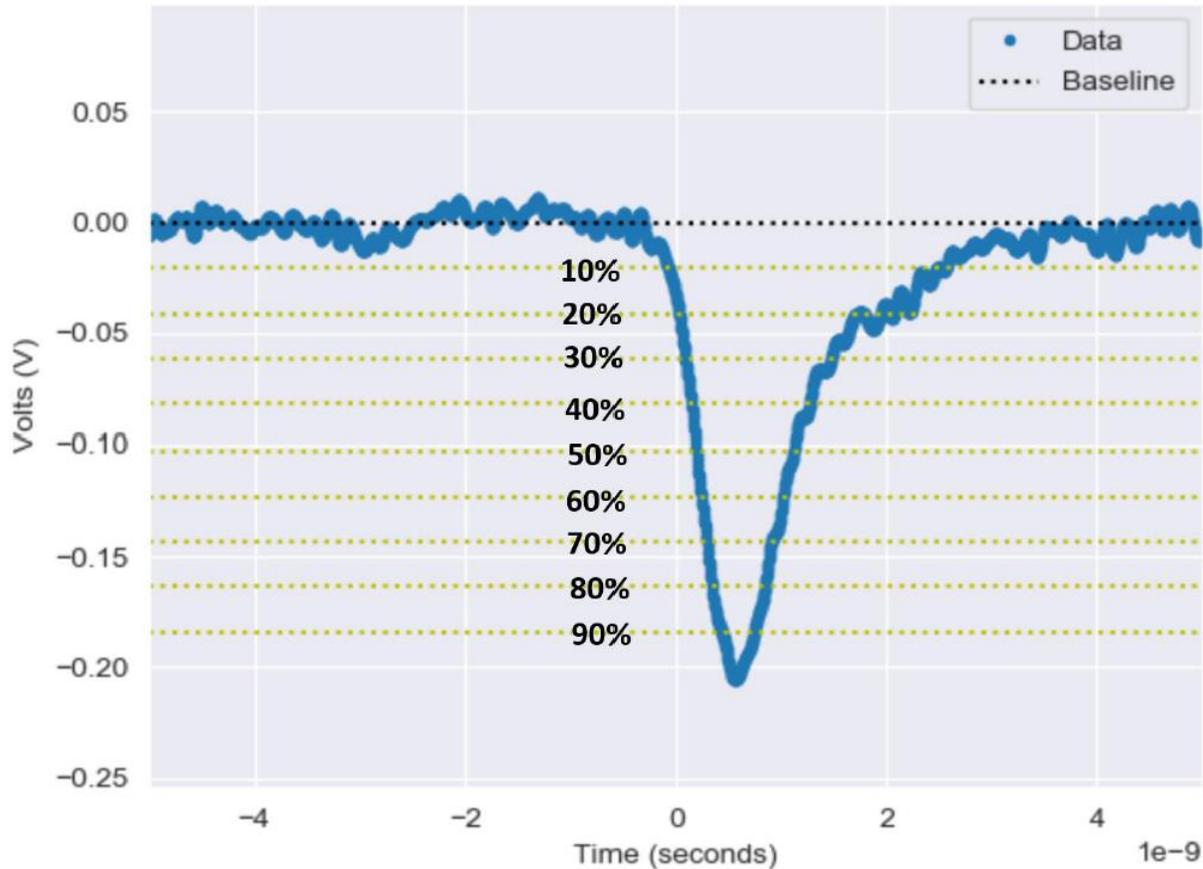
- Components:
 - ^{90}Sr source holder
 - Timing printed circuit board (PCB)
- DAQ: Fast Oscilloscope
 - effective resolution: 3.13 ps
 - Two channels used
 - Event selection: AND qualifier, trigger over threshold
- Alignment ensured through four screws at each corner
- Entire setup placed in climate chamber for temperature control
 - Dry air constantly pumped to avoid humidity issues



^{90}Sr Source Holder



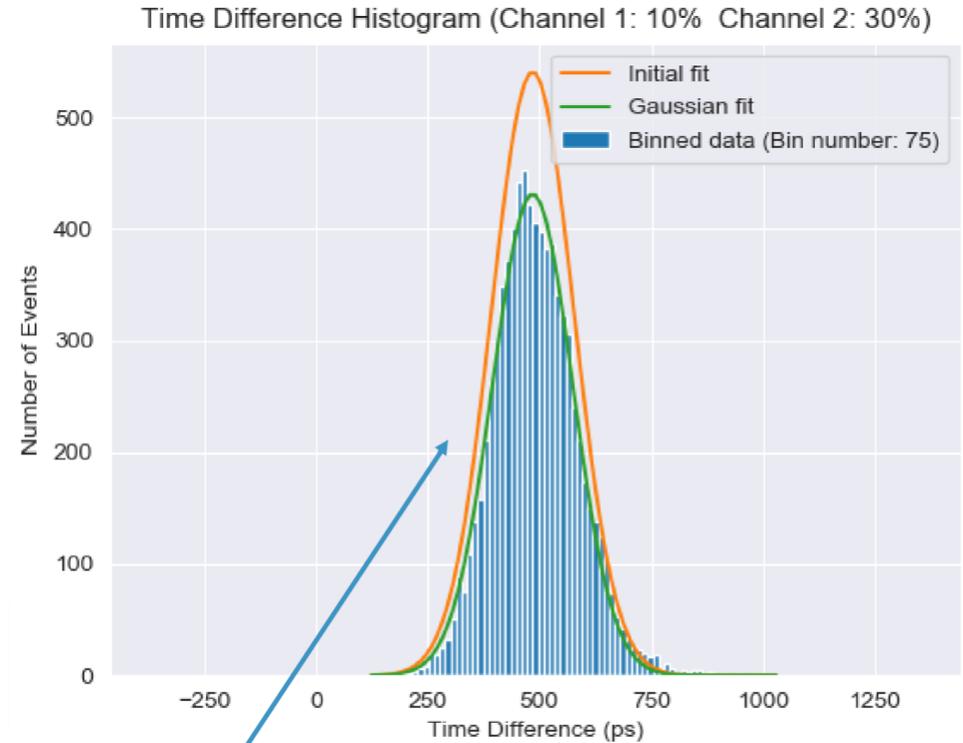
Analysis Procedure, Part 1



- Constant Fraction Discrimination Method was used
 - Entire analysis procedure done by dedicated python script
- Define time of arrival (ToA) at thresholds in signal's rising edge that is certain percentage of signal amplitude
- Two fits are used:
 - Quadratic fit: 20 points (~ 60 ps) to approximate peak position
 - Linear fit: 12 points (~ 36 ps) centered at closest data point to threshold to approximate time of arrival

Analysis Procedure, Part 2

- Subtract CH2's ToA to CH1's ToA to get time difference
 - Done for all possible combinations of thresholds (81 total)
- Binning yield Gaussian distribution
 - Optimal Bin size selection through Shimazaki-Shinomoto method (mean integrated squared error minimisation)
- Sigma of Gaussian is the time resolution



Time difference histogram of ~8000 events comparing signal from forward device's 10% threshold to rear device's 30% threshold

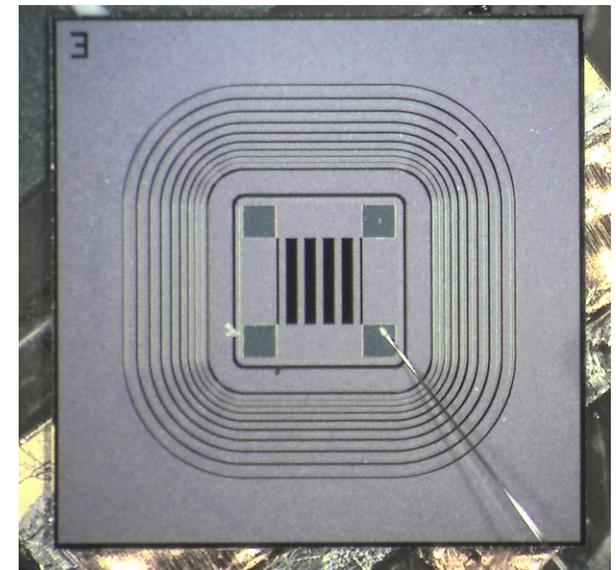
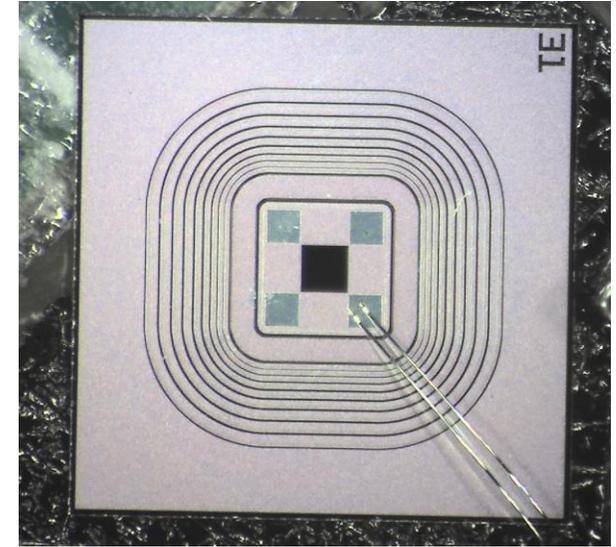
Analysis Procedure, Part 3

- Error Analysis procedure:
 - Rerun same experiment multiple times while switching off power in-between (done 5 times)
 - Uncertainty is the standard deviation of the time resolutions
 - Done for only one voltage value to save time
- Assumed devices have similar timing resolution to get the device's timing resolution

$$\begin{aligned}\sigma_{average}^2 &= \sigma_{DUT_1}^2 + \sigma_{DUT_2}^2 \\ \Rightarrow \sigma_{DUT} &= \frac{\sigma_{average}}{\sqrt{2}}\end{aligned}$$

Devices Tested

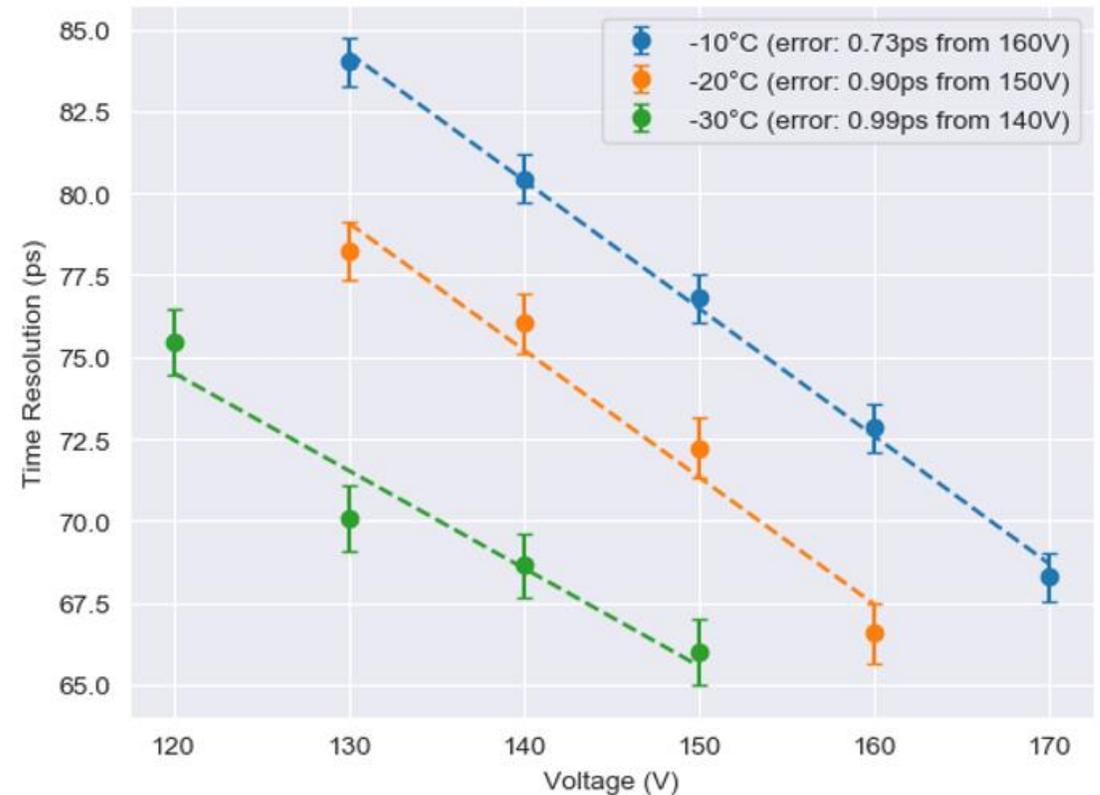
- Multiple LGAD Wafers produced ($200\mu\text{m}$ wafer for gain studies, etc.) by Micron Semiconductor Ltd.
 - $50\mu\text{m}$ wafer for timing studies
 - Top right: 1 x 1 pad with pixel size of 1mm
 - Bottom right: 1 x 1 pad with pixel size of 1.3mm
- CNM devices: Run 9088 W7 LGB31 and LGB52
 - Thickness: $45\mu\text{m}$
- Gain and IVs measurements of devices are work in progress



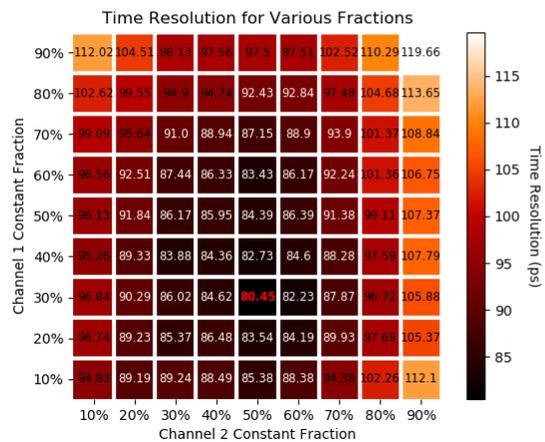
Results: CNM Devices

- ~2000 events per measurement run
- Taken February 2020
- Same bias voltage applied to both devices
- Show clear dependence with voltage and temperature

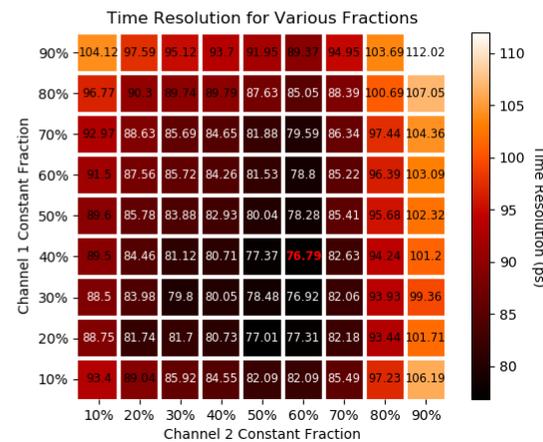
Time Resolution for Various Voltages (CNM LGB31 & CNM LGB52)



CNM Devices (140V, -10°C)



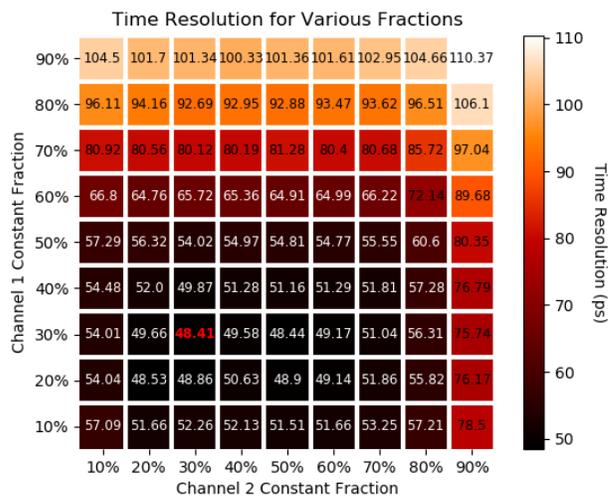
CNM Devices (150V, -10°C)



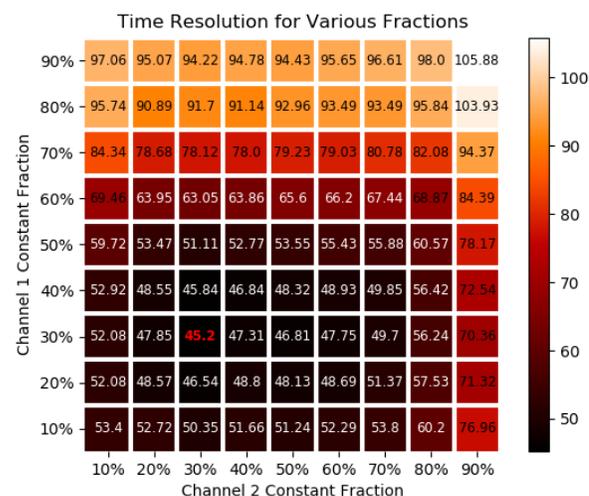
Results: Micron and CNM Devices

- ~2000 events per measurement run
- Same bias voltage applied for both devices
- Again see clear temperature and voltage dependence

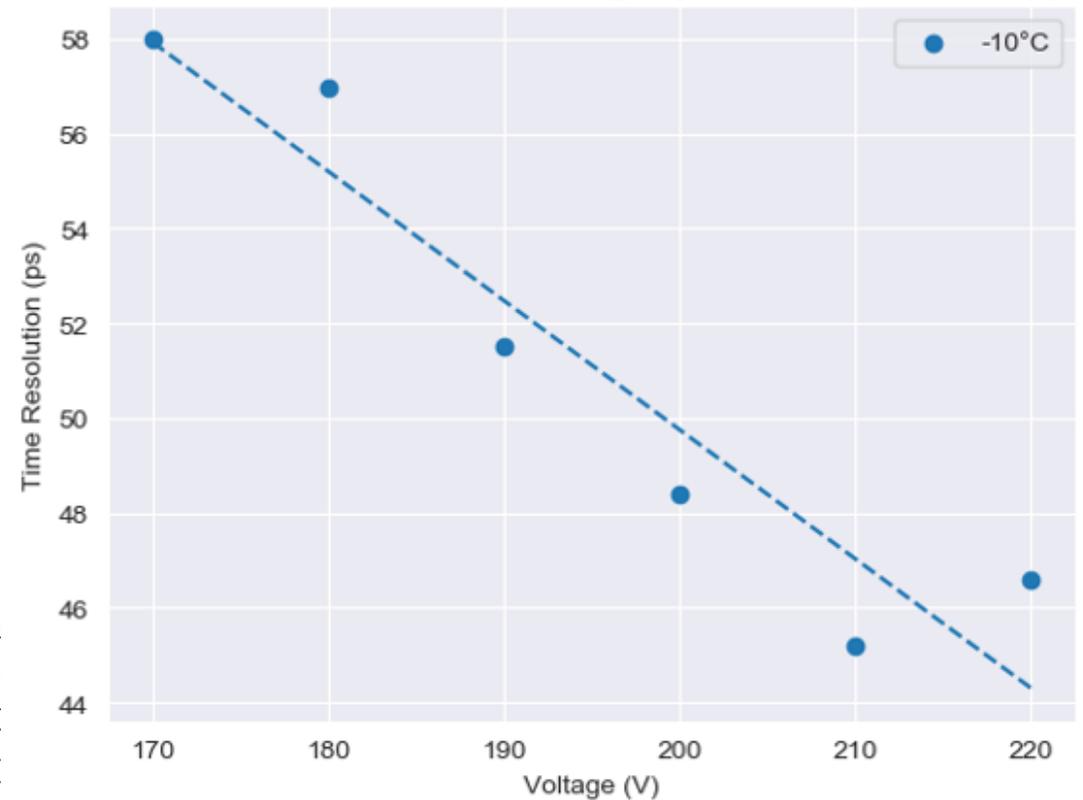
CNM & Micron Devices (200V, -10°C)



CNM & Micron Devices (210V, -10°C)



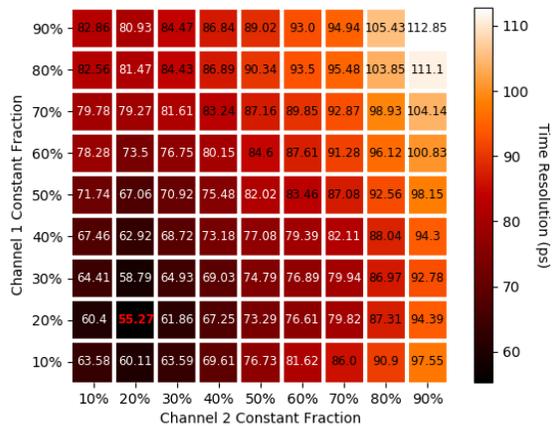
Time Resolution for Various Voltages (Micron31 & CNM LGB52)



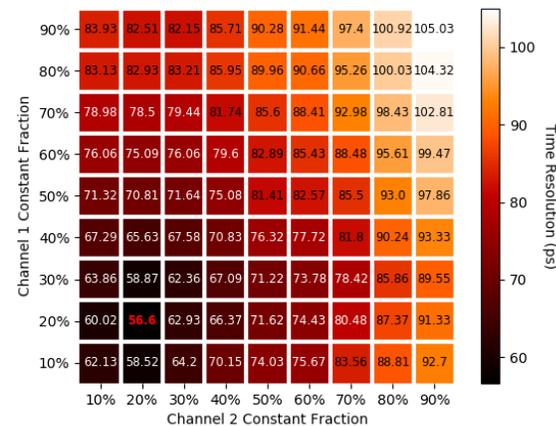
Results: Micron Devices

- ~2000 events per measurement run
- Different voltages applied for different devices
- Less obvious dependence with temperature and voltage
- Likely due to saturated gain in tested range.

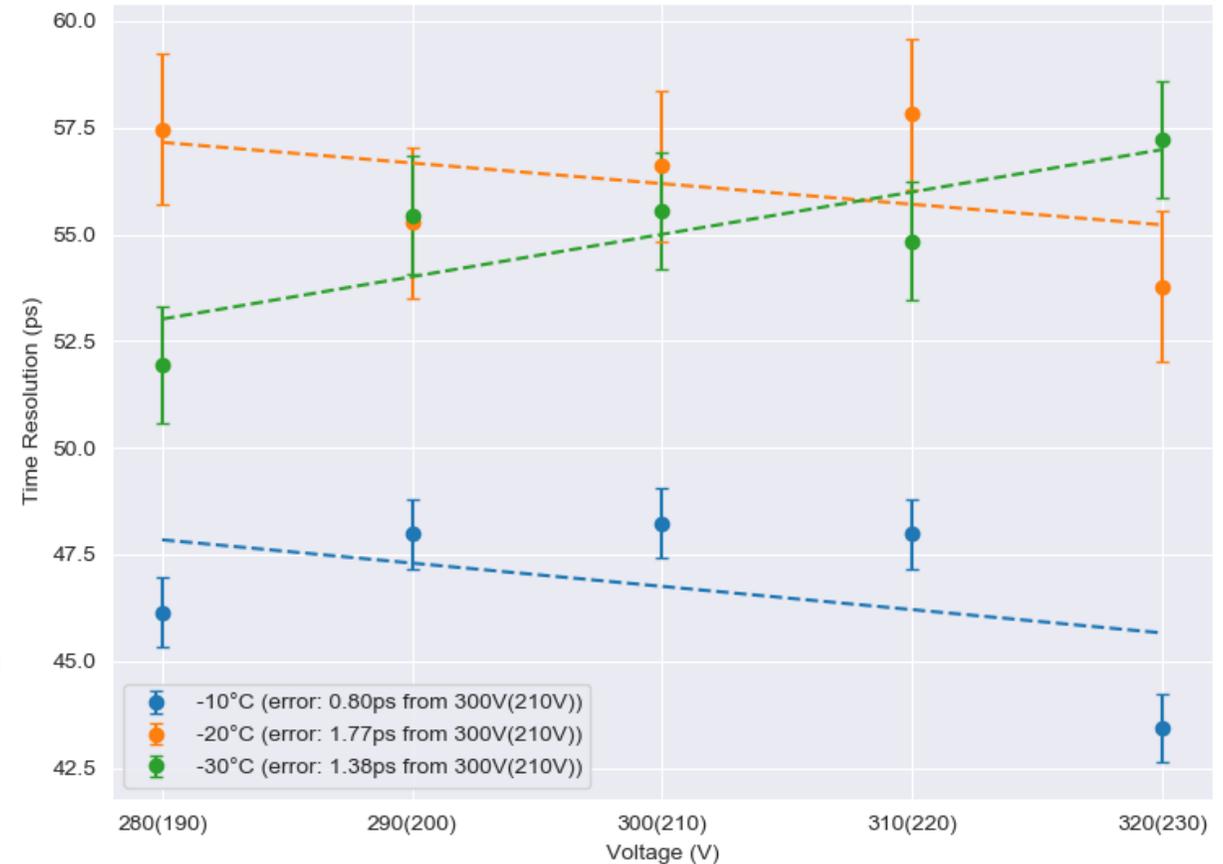
Micron Devices (290V (200V), -20°C)
Time Resolution for Various Fractions



Micron Devices (300V (210V), -20°C)
Time Resolution for Various Fractions



Time Resolution for Various Voltages (Micron31 & Micron3)



Micron 31 goes from 280V – 320V
Micron 3 goes from 190V – 230V

Future Work and Summary

- Future Work:
 - Further measurements of devices
 - Timing studies after irradiation
- Summary:
 - Timing Requirements of LGADs
 - Experimental Setup for coincidence measurements
 - Analysis procedure
 - Timing results of LGADs produced by Micron Semiconductor Ltd.
 - $\sim 55ps$, with the lowest being $\sim 43ps$

**Thank you for your
Attention!
Questions?**